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GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

May 5, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG798601706

Report verification at [igi.org](#)

PROPORTIONS



Sample Image Used

CLARITY CHARACTERISTICS

KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VS¹⁻² VS¹⁻² SI¹⁻² I¹⁻³

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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LABORATORY GROWN DIAMOND

OVAL BRILLIANT

8.11 X 5.75 X 3.50 MM

1.03 CARAT

D

VVS 2

EXCELLENT

EXCELLENT

NONE

IGI LG798601706

May 5, 2026

IGI Report No LG798601706

OVAL BRILLIANT

8.11 X 5.75 X 3.50 MM

Carat Weight

Color Grade

Clarity Grade

Table

Girdle

Medium To Slightly Thick (Faceted)

Culet

Polish

Symmetry

Fluorescence

Inscription(s)

1.03 CARAT

D

VVS 2

60.9%

61%

Pointed

EXCELLENT

EXCELLENT

NONE

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